



UNIVERSITY OF KASHMIR  
(NACC Accredited Grade-A+)  
Hazratbal, Srinagar  
190006, J&K, India

## Department of Chemistry University of Kashmir

KU2019-CHEM

Dated: 18-06-2019

Applications are invited for one post of Junior Research Fellow (JRF) in Department of Science and Technology (DST) funded project titled: 'Surface Interrogation Scanning Electrochemical Microscopy (SI-SECM) Screening of Metal nanoparticle Coupled Semiconductor nanocomposites for Photo-Oxidation/reduction of Water and CO<sub>2</sub>' for three years. The post is purely temporary and co-terminus with the project.

**Essential qualification:** Candidates with M.Sc. degree in Chemistry with a minimum of 60% marks. Candidates who have qualified CSIR-UGC-NET/JRF/GATE will be preferred. Selected candidates can enrol themselves for the Ph.D. program of Kashmir University, following selection procedure of the university. A good academic record, inquisitiveness to do science and basic knowledge of electrochemistry and Materials Chemistry is desirable. Interested candidates may submit their application on plain paper along with detailed CV (mention email and Phone NO) supported by photo-copies of Marks sheets and testimonials to the office of the Department of Chemistry University of Kashmir. Applications as scanned copies can also be emailed to the email id: [mohsin@kashmiruniversity.ac.in](mailto:mohsin@kashmiruniversity.ac.in); [nanoelectrochem@gmail.com](mailto:nanoelectrochem@gmail.com)

### Important Deadlines:

**Last date for submission of applications:** 25<sup>th</sup> June 2019.

**Intimation to the shortlisted candidates for Interview:** 27<sup>th</sup> June 2019.

**Date of Interview:** 3<sup>rd</sup> July 2019.

**Place of Interview:** Office of the Head, Department of Chemistry, University of Kashmir, Srinagar.

No TA/DA is permissible if called for interview.

(Mohsin Ahmad Bhat)

Principal Investigator,

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